IN THE CLAIMS:

Please cancel claims 5, 6, 15, 36 and 44-46 without prejudice, and amend the claims as follows:

 (Currently amended) A method for detecting a polishing endpoint, comprising:

providing a cell body defining an electrolyte-containing volume, wherein the electrolyte-containing volume contains at least electrolyte;

positioning a substrate in contact with a polishing pad at least partially submersed in the electrolyte;

electropolishing one or more conductive materials on the substrate;

delivering an electrical signal through the electrolyte; and

detecting <u>at least one of an increase in a voltage and a decrease in a current of</u> the <u>electrical signal to determine</u> the polishing endpoint of the electropolishing.

- 2. (Original) The method of claim 1, further comprising causing relative motion between the substrate and the pad during the electropolishing.
- 3. (Original) The method of claim 1, wherein electropolishing comprises removing at least a portion of the one or more conductive materials by electrochemical activity.
- 4. (Original) The method of claim 1, wherein electropolishing comprises delivering an electrical signal through the electrolyte between a first electrode and a second electrode, wherein only the first electrode is positionable in direct physical contact with the substrate.
- 5. (Cancelled).
- 6. (Cancelled).

- 7. (Currently amended) The method of claim [[5]] 1, wherein detecting the polishing endpoint comprises monitoring a signal characteristic of the electrical signal.
- 8. (Original) The method of claim 7, wherein monitoring the signal characteristic of the electrical signal comprises monitoring at least one of a voltage and a current of the electrical signal.
- (Currently amended) A method for detecting a polishing endpoint, comprising:

providing a cell body defining an electrolyte-containing volume, wherein the electrolyte-containing volume contains at least electrolyte;

positioning a substrate in contact with a polishing pad at least partially submersed in the electrolyte;

establishing a potential difference between a first electrode and a second electrode disposed in the electrolyte in order to produce a current through the electrolyte, wherein at least the first electrode is not disposed on a polishing surface of the polishing pad;

electropolishing one or more conductive materials on the substrate; and detecting at least one of an increase in a voltage and a decrease in a current of the electrical signal to determine the polishing endpoint of the electropolishing according to at least one of the potential difference and the current.

- 10. (Original) The method of claim 9, wherein the first electrode is disposed on a floor of the cell body below the polishing pad.
- 11. (Original) The method of claim 9, wherein the polishing pad is conductive.
- 12. (Original) The method of claim 9, further comprising continuing to polish the substrate for a period of time after detecting the polishing endpoint.

- 13. (Original) The method of claim 9, further comprising causing relative motion between the substrate and the pad during the electropolishing.
- 14. (Original) The method of claim 9, wherein electropolishing comprises removing at least a portion of the one or more conductive materials by electrochemical activity.
- 15. (Cancelled).
- 16. (Original) The method of claim 9, further comprising initiating a continuing polishing step upon detection of the polishing endpoint.
- 17. (Currently amended) A computer readable medium containing a program which, when executed, performs an operation for detecting a polishing endpoint of an electropolishing process occurring for a substrate in contact with a polishing pad at least partially submersed in the electrolyte, the operation comprising:

detecting the polishing endpoint of the electropolishing according to at least [[on]] one of a voltage and a current of an electrical signal delivered through at least the electrolyte.

- 18. (Original) The computer readable medium of claim 17, wherein the electropolishing comprises relative motion between the substrate and the pad.
- 19. (Original) The computer readable medium of claim 17, wherein the electropolishing comprises anodic dissolution induced by the electrical signal.
- 20. (Original) The computer readable medium of claim 17, wherein electropolishing comprises removing at least a portion of one or more conductive materials on the substrate by electrochemical activity.

- 21. (Original) The computer readable medium of claim 17, wherein the operation further comprises initiating a continuing polishing step upon detection of the polishing endpoint.
- 22. (Original) The computer readable medium of claim 17, wherein the operation further comprises changing a voltage value of the electrical signal after detection of a change in a slope of the electrical signal.
- 23. (Original) The computer readable medium of claim 17, wherein program comprises a process recipe comprising a plurality of voltage values for the electrical signal and wherein the operation further comprises selecting the voltage values according to polishing transition points.
- 24. (Original) The computer readable medium of claim 17, wherein the operation further comprises changing a voltage value of the electrical signal after detecting the polishing endpoint.
- 25. (Original) The computer readable medium of claim 17, wherein detecting the polishing endpoint comprises detecting at least one of an increase in the voltage and a decrease in the current of the electrical signal.
- 26. (Original) The computer readable medium of claim 25, wherein monitoring the signal characteristic of the electrical signal comprises monitoring at least one of a voltage and a current of the electrical signal.
- 27. (Currently amended) An electro-chemical mechanical polishing system, comprising:
 - a cell body defining an electrolyte-containing volume;
 - a polishing pad disposed in the electrolyte-containing volume;
- a power supply configured to supply an electrical signal to <u>an</u> electrolyte contained in the electrolyte-containing volume; and

an endpoint detection system configured to monitor <u>an increase in a voltage or a</u> <u>decrease in a current a signal characteristic</u> of the electrical signal to detect a polishing endpoint.

- 28. (Original) The system of claim 27, further comprising a reference electrode.
- 29. (Original) The system of claim 27, wherein the polishing pad is conductive.
- 30. (Original) The system of claim 27, further comprising a controller operably connected to the endpoint detection system and configured to halt a polishing cycle upon detection of the polishing endpoint by the endpoint detection system.
- 31. (Original) The system of claim 27, further comprising a controller operably connected to the endpoint detection system and configured to initiate a continuing polishing step upon detection of the polishing endpoint by the endpoint detection system.
- 32. (Original) The system of claim 27, further comprising a controller operably connected to the endpoint detection system and the power supply and configured to change a voltage value of the electrical signal upon detection of a change in a slope of the electrical signal by the endpoint detection system.
- 33. (Original) The system of claim 27, further comprising a controller operably connected to the endpoint detection system and the power supply and configured to execute a process recipe comprising a plurality of voltage values for the electrical signal, wherein the controller is configured to select the voltage values according to polishing transition points.
- 34. (Original) The system of claim 27, further comprising a controller operably connected to the endpoint detection system and the power supply and configured to

1

change a voltage value of the electrical signal upon detection of the polishing endpoint by the endpoint detection system.

- 35. (Original) The system of claim 27, further comprising an electrolyte container to provide the electrolyte-containing volume with electrolyte.
- 36. (Cancelled).
- 37. (Original) The system of claim 27, further comprising:
- a first electrode disposed in the electrolyte-containing volume and connected to a first terminal of the power supply; and
- a second electrode disposed in the electrolyte-containing volume and connected to a second terminal of the power supply.
- 38. (Original) The system of claim 37, wherein the first electrode is disposed on a wall of the cell body.
- 39. (Original) The system of claim 37, wherein the first electrode is disposed on the pad.
- 40. (Original) The system of claim 39, wherein the second electrode is not disposed on the pad.
- 41. (Original) The system of claim 27, wherein the pad comprises an electrically conductive medium located on a polishing surface of the pad and wherein a first terminal of the power supply is electrically connected to the electrically conductive medium.
- 42. (Original) The system of claim 41, wherein the polishing surface is non-conductive.

43. (Original) The system of claim 41, wherein a second terminal of the power supply is electrically connected to an electrode disposed in the electrolyte-containing volume.

Claims 44 - 46 (Cancelled).